

Supporting Information

**MOF-Derived CoSe₂ Microspheres with Hollow Interiors as
High-Performance Electrocatalysts for Enhanced Oxygen
Evolution Reaction**

*Xiaobin Liu, Yongchang Liu, Li-Zhen Fan**

Key Laboratory of New Energy Materials and Technologies, Institute of Advanced
Materials and Technology, University of Science and Technology Beijing, Beijing
100083, China

*Tel./fax: +86 10 62334311. E-mail: fanlizhen@ustb.edu.cn (L.-Z. Fan).

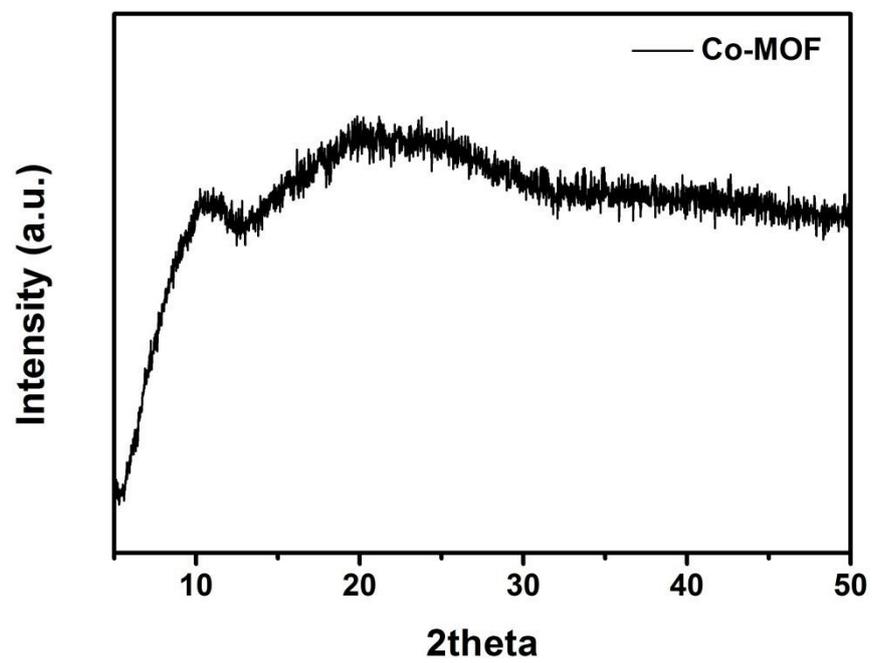


Fig. S1 XRD pattern of Co-MOF.

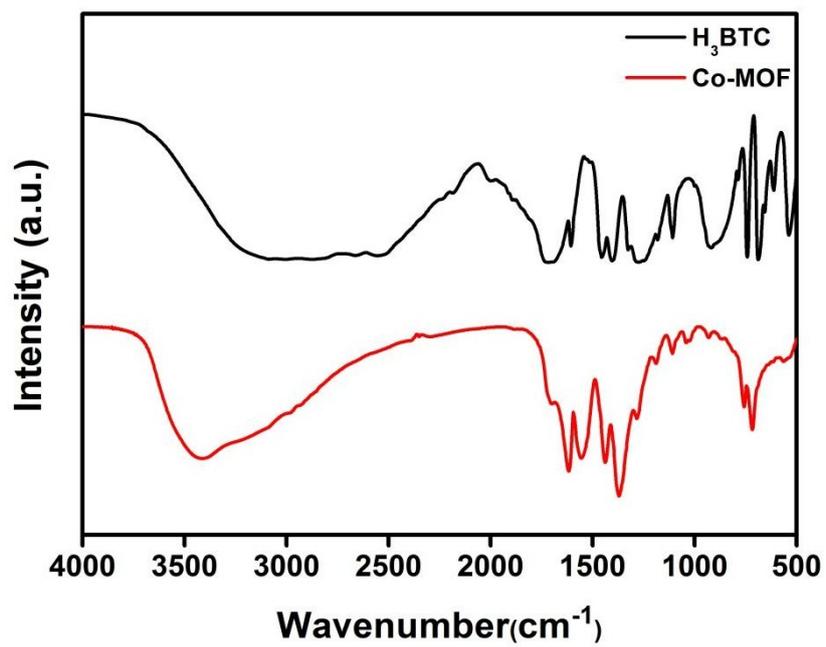


Fig. S2 FT-IR spectra of Co-MOF and H_3BTC .

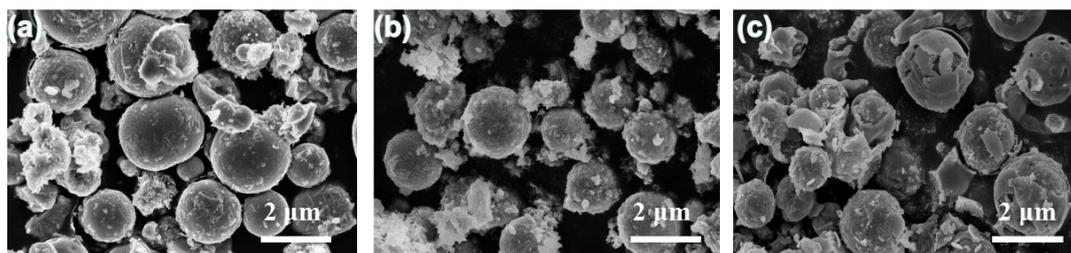


Fig. S3 SEM images of (a) CoSe_2 -400, (b) CoSe_2 -450, and (c) CoSe_2 -550.

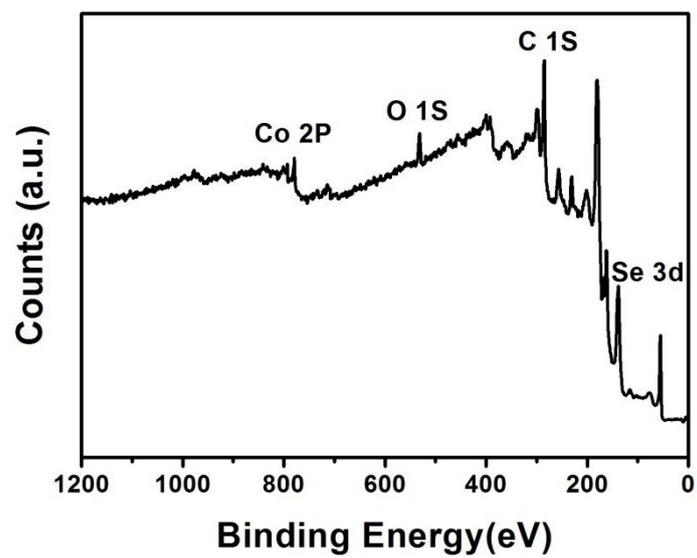


Fig. S4 Survey XPS spectrum of CoSe₂-450.

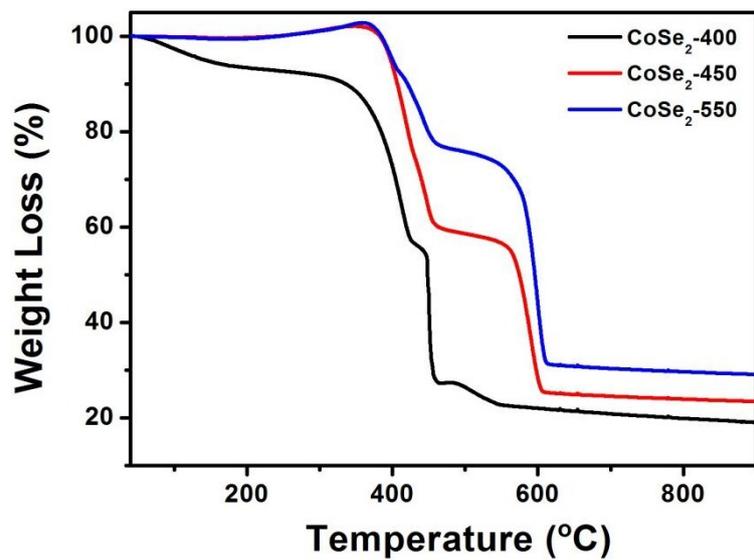
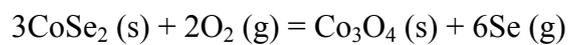


Fig. S5 TGA plots of CoSe₂-400, CoSe₂-450, and CoSe₂-550.

Table S1. The contents of CoSe₂ and carbon of CoSe₂-400, CoSe₂-450 and CoSe₂-550.



Catalysts	CoSe ₂ (%)	C (%)
CoSe ₂ -400	78.8	21.2
CoSe ₂ -450	64.1	35.9
CoSe ₂ -550	52.6	47.4

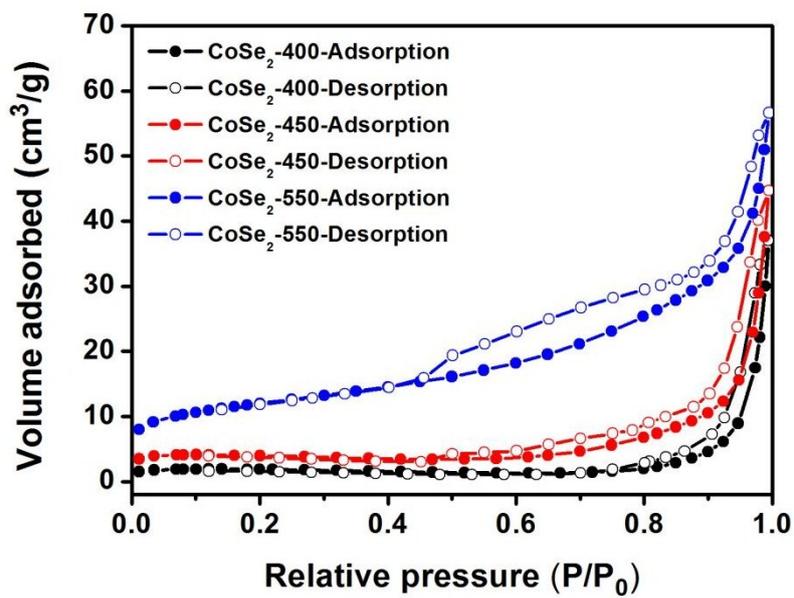


Fig. S6 Nitrogen adsorption-desorption isotherms of CoSe₂-400, CoSe₂-450, and CoSe₂-550.

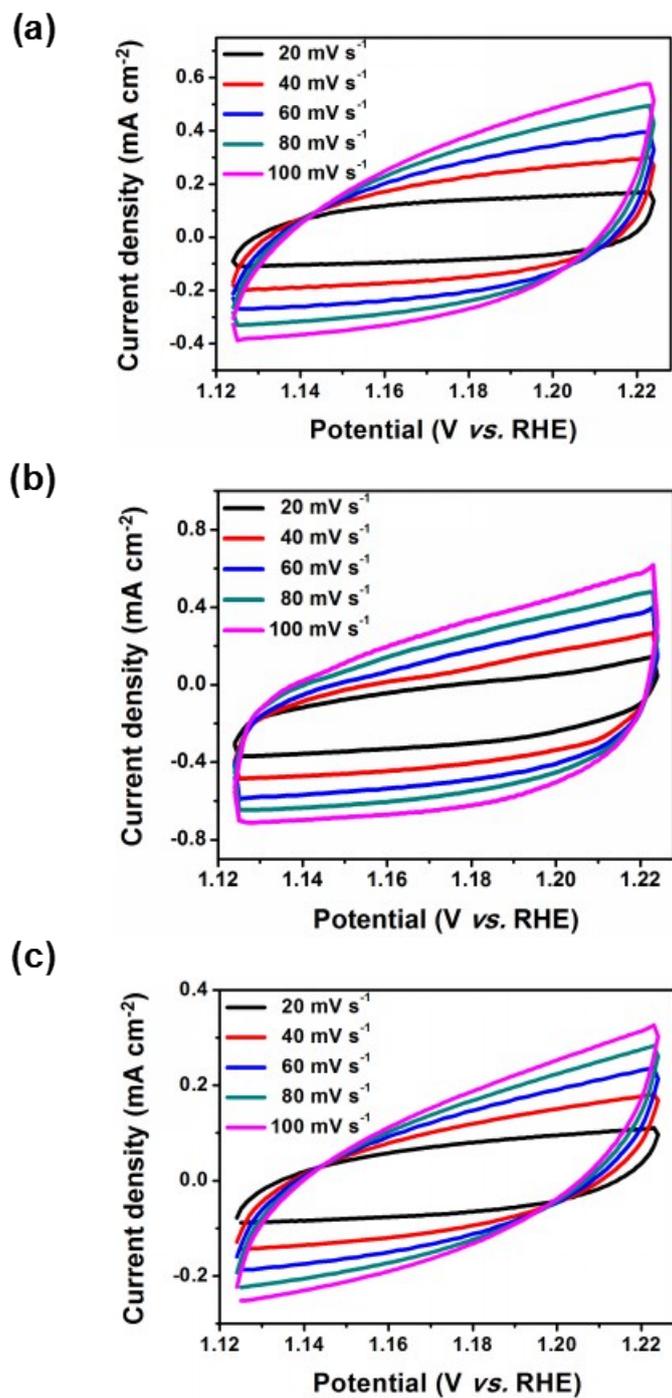


Fig. S7 Cyclic voltammograms (1.124–1.224 V vs RHE) of (a) CoSe₂-400, (b) CoSe₂-450, and (c) CoSe₂-550 recorded in 1.0 M KOH.

Table S2. Comparison of OER performance for CoSe₂-450 with other CoSe₂ OER electrocatalyst.

Electrocatalysts	Onset potential (V vs. RHE)	Overpotential (mV vs.RHE)	Tafel slope (mV/dec)	Refs.
CoSe ₂ -450	1.48	330	79	This work
Zn-doped CoSe ₂ /CFC	1.35	356	88	[S1]
NG-CoSe ₂ nanobelt	1.52	370	40	[S2]
Mn ₃ O ₄ /CoSe ₂ nanobelt	1.60	450	49	[S3]
ultrathin CoSe ₂	1.49	320	44	[S4]
CoO/CoSe ₂	1.55	337	137	[S5]

Supplementary References

[S1] Q. C. Dong, Q. Wang, Z. Y. Dai, H. J. Qiu and X. C. Dong, *ACS Appl. Mater. Interfaces*, 2016, **8**, 26902-26907.

[S2] M. Gao, X. Cao, Q. Gao, Y. Xu, Y. Zheng, J. Jiang and S. H. Yu, *ACS Nano*, 2014, **8**, 3970-3978.

[S3] M. Gao, Y. Xu, J. Jiang, Y. Zheng and S. H. Yu, *J. Am. Chem. Soc.*, 2012, **134**, 2930-2933.

[S4] Y. Liu, H. Cheng, M. Lyu, S. Fan, Q. Liu, W. Zhang, Y. Zhi, C. Wang, C. Xiao and S. Wei, *J. Am. Chem. Soc.*, 2014, **136**, 15670-15675.

[S5] K. D. Li, J. F. Zhang, R. Wu, Y. F. Yu and B. Zhang, *Adv. Sci.*, 2016, **3**, 1500426-1500433.